



ISTITUTO ITALIANO  
DI TECNOLOGIA

## TITLE

Substrate regenerative process for SERS detection without masks

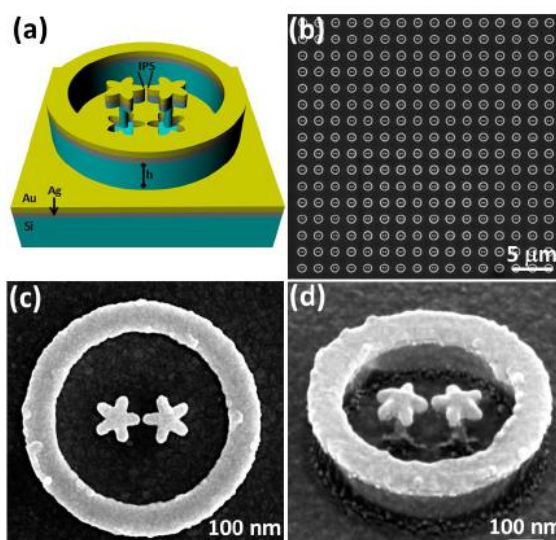
## INVENTORS

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## DESCRIPTION

The present invention arises in the field of devices comprising metallic nanostructures functionalized with organic analytes or biomolecules. It can be used in spectroscopy as sensors.

In particular, the invention relates to a process which allows the reuse of these devices using a maskless approach based on adequate structuring the three-dimensional (3D) with undercut of the substrate departure. This approach allows a complete and absolute removal of the analytes.



## APPLICATIONS

Sensor, spectroscopy, analytes removal

## KEYWORDS

Metallic, nanostructures, spectroscopy, maskless, 3D, sensor

## BIBLIOGRAPHIC DATA

Procedimento Di Rigenerazione Di Substrati Per Rilevazione SERS Senza Utilizzo Di Maschere

Application Number IT RM2014A000320

Priority Date June 18, 2014

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